## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Seetharaman Sridhar

Docket No.: TI-31408

Serial No:

**TBD** 

Examiner: TBD

Filed:

11/08/01

Art Unit:

**TBD** 

For:

PROCESS TO IMPROVE NWELL-NWELL ISOLATION WITH A

BLANKET LOW DOSE HIGH ENERGY IMPLANT

## PRELIMINARY AMENDMENT

November 8, 2001

**Assistant Commissioner for Patents** 

Washington, DC 20231

Dear Sir:

Please amend the above referenced application as follows:

## In the Specification:

Page 1, before line 1, insert -- This application claims priority under 35 USC § 119(e)(1) of provisional application number 60/259,298 filed 12/31/00.--

## **REMARKS**

Entry of the foregoing amendment prior to examination is respectfully requested.

If the Examiner has any questions or other correspondence regarding this application, Applicant requests that the Examiner contact Applicant's attorney at the below listed telephone number and address.

Respectfully submitted,

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